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Lori Valdes

Assistant Commissioner for Patents
Washington, D.C. 20231

Attorney Docket No. 00120/HG

Pursuant to 37 CFR 1.53(b), transmitted herewith for filing is the patent application of

Inventor(s):

Toshikazu MUKAIHARA
Takeharu YAMAGUCHI
Akihiko KASUKAWA

Title: SEMICONDUCTOR LASER DEVICE

Priority Claim (35 U.S.C. 119) is made, based upon:

Japanese Patent Application No. 11-162792 filed June 9, 1999.

Enclosed herewith are:

- Specification (Description, Claims, Abstract): Pages 1 - 16; Number of claims 1 - 5
- Declaration and Power of Attorney (executed)
- 5 Sheets of drawings, Figures 1 - 9 Formal Informal
- Assignment and Form PTO-1595 Recordation Form Cover Sheet and Check for \$40.00
- Certified copy of priority document identified above
- Information Disclosure Statement including Form PTO-1449
- Preliminary Amendment to remove multiple dependent claims
- Verified Statement(s) Claiming Small Entity Status
- Receipt Postcard

	Number Filed	Number Extra	Rate	Calculations
Total Claims	<u>8</u> - 20 = <u>0</u>		x \$18.00 =	\$ --
Independent Claims	<u>1</u> - 3 = <u>0</u>		x \$78.00 =	\$ --
MULTIPLE DEPENDENT CLAIMS			+ \$260.00 =	\$ --
			BASIC FEE	\$ 690.00
			Total of above Calculations	\$ <u>690.00</u>

To the extent not tendered by check, authorization is given to charge any fees under 37 CFR 1.16 and 1.17 during pendency of the application, or to credit any overpayment, to Deposit Account No. 06-1378. Duplicate copy of this letter is enclosed.

FRISHAUF, HOLTZ, GOODMAN, LANGER & CHICK, P.C.

By:

HERBERT GOODMAN - Reg. No. 17,081

HG/Ipv
Encs.

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Attorney Docket No. 00120/HG

**IN THE UNITED STATES PATENT
AND TRADEMARK OFFICE**

Applicant(s) : Toshikazu MUKAIHARA et al

Serial No. :

Filed : Concomitantly herewith

For : SEMICONDUCTOR LASER DEVICE

Art Unit :

Examiner :

**PRELIMINARY AMENDMENT FILED
CONCOMITANT WITH APPLICATION**

Assistant Commissioner for Patents
Washington, D.C. 20231

S I R :

Please amend the application as follows:

IN THE CLAIMS:

Claim 5, line 1, delete "any";

line 2, replace "one of claims 1 to 4" with
--claim 1--.

Please add the following claims 6-8.

6. The semiconductor laser device according to claim 2,
wherein the coefficient of light confinement to the active layer
ranges from 1% to 2%.

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Lori Valdes

Lori Valdes

In the event that this Paper is late filed, and the necessary petition for extension of time is not filed concurrently herewith, please consider this as a Petition for the requisite extension of time, and to the extent not tendered by check attached hereto, authorization to charge the extension fee, or any other fee required in connection with this Paper, to Account No. 06-1378.

7. The semiconductor laser device according to claim 3,
wherein the coefficient of light confinement to the active layer
ranges from 1% to 2%.

8. The semiconductor laser device according to claim 4,
wherein the coefficient of light confinement to the active layer
ranges from 1% to 2%.

REMARKS

The present amendment removes all multiple dependent claims
without changing the scope of coverage.

Respectfully submitted,



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SEMICONDUCTOR LASER DEVICE

BACKGROUND OF THE INVENTION

Field of the Invention

5 The present invention relates to a semiconductor laser device, and more specifically, to a semiconductor laser device adapted for use as a pumping light source for optical fiber amplifier, such as a laser device of the gain-waveguide type that oscillates with a wavelength of,
10 e.g., 0.98 μm and requires high optical output of hundreds of mW, and capable of ensuring a linear current-optical output characteristic even during high-current operation.

Prior Art

In a semiconductor laser device that has an active
15 layer (quantum region) formed of a quantum well structure, injected carriers are quantized toward quantum wells, and the state density of carrier energy is stepped.
Accordingly, the gain coefficient suddenly rises in response to driving current, so that a laser beam can be
20 oscillated even with use of a low threshold current density. The semiconductor laser device of this type delivers higher optical output than a semiconductor laser device that includes an active layer of a bulk semiconductor, so that it is being studied for practical use as a pumping light
25 source for optical fiber amplifier.

For example, the following semiconductor laser device that oscillates with a wavelength of 0.98 μm is an object of investigation as a pumping light source for optical fiber amplifier. This device will now be described with
30 reference to the accompanying drawings.

FIG. 1 is a side view showing the semiconductor laser device, and FIG. 2 is a sectional view taken along line II-

II of FIG. 1.

- The device has a layer structure of a semiconductor material, including a lower clad layer 2 of n-AlGaAs, an active layer 3 of a quantum-well structure made of InGaAs and GaAs, an upper clad layer 4 of p-AlGaAs, and a cap layer 5 of p-GaAs, which are stacked in layers on an n-GaAs substrate 1. A part of the upper clad layer 4 and the cap layer 5 form a mesa structure, and a passivation film 6 of SiN is formed on the lateral of the mesa structure.
- Further, an upper electrode 7 of Ti/Pt/Au is formed on the cap layer 5 and the passivation film 6, and a lower electrode 8 of AuGe/Ni/Au is formed on the back surface of the substrate 1.

- The device A is manufactured in the following manner.
- The aforesaid layer structure is formed on the n-GaAs substrate by, for example, the MOCVD method, and the upper and lower electrodes are formed on the upper and lower surfaces, respectively, of the layer structure. Thereafter, the resulting structure is cleft with a given cavity length L, a low-reflection film 9 of, e.g., SiN is formed on one end face (front facet) S_1 of the structure, and a high-reflection film 10 of, e.g., SiO_2/Si is formed on the other end face (rear facet) S_2 .

In the case of the device A having this mesa structure, it is believed that high optical output can be effectively obtained by increasing the cavity length L. This is because if the cavity length L increases, the influence of heat can be lessened, so that high-optical output can be expected. If the cavity length is too long, however, the differential quantum efficiency of the device A lowers, so that higher current is required for high-optical output operation. Normally, therefore, the cavity

length L of the device A with this construction is designed so that the cavity length L is not longer than 1,000 μm .

The inventors hereof examined the current-optical output characteristic for the case where the cavity length 5 L of the device A with the layer structure shown in FIGS. 1 and 2 was adjusted to 800 μm . Thereupon, the characteristic curve of FIG. 3 and the following new knowledge were obtained.

When a driving current (A_1) of about 200 mA was 10 injected, as seen from FIG. 3, a first kink (a_1) was generated in the optical output, and the existing linear relation between the driving current and the optical output disappeared. If the driving current was further increased to a level (A_2) of about 500 mA, a second kink (a_2) was 15 generated in the optical output. Thus, in the case of the device A, the two kinks a_1 and a_2 were generated in the current-optical output characteristic curve as the driving current was increased.

Accordingly, the inventors hereof first closely 20 examined the oscillation spectrum of the device A. The following is a description of the results of the examination.

(1) FIG. 4 shows an oscillation spectrum obtained when the injected current was at about 200 mA.

25 As seen from this oscillation spectrum, there is a small number of longitudinal modes which oscillate actually in a gain band g. The intensity of a central longitudinal oscillation mode B_0 is 5 dB or more higher than those of side modes B_1 and B_2 . As a whole, single longitudinal mode 30 oscillation that is prescribed by the central longitudinal oscillation mode B_0 is dominant.

(2) An oscillation spectrum obtained when the first

kink (a_1) was generated indicates that the central longitudinal oscillation mode B_0 jumps to the side mode B_1 at a distance of about 0.4 nm therefrom when the gain band shifts to the longer wavelength side as the temperature of 5 the device rises with the increase of the injected current.

The probability of generation of single longitudinal mode oscillation is related to a spontaneous emission factor (β_{sp}) given by

$$\beta_{sp} = \Gamma \cdot \lambda^4 \cdot K / 4\pi^2 \cdot n^3 \cdot V \cdot \delta\lambda, \quad \dots (1)$$

10 where Γ is the confinement coefficient of the active layer, λ is an oscillation wavelength, K is a factor reflective of the complexity of the electric field for a transverse mode, n is an equivalent refractive index, V is the volume of the active layer, and $\delta\lambda$ is the half width of the spontaneous 15 emission spectrum. It is believed that the smaller the value β_{sp} , the higher the probability of generation of single longitudinal mode oscillation is.

In the case of the device A, therefore, the oscillation wavelength (λ) is as short as 0.98 μm , so that 20 β_{sp} is lowered in proportion to the fourth power of λ . Accordingly, the device A can be supposed to be able to cause single longitudinal mode oscillation with high probability.

The following problem will be aroused, however, if a 25 module is constructed in a manner such that the device A that undergoes single longitudinal mode oscillation is connected to an optical fiber. A laser beam generated by single longitudinal mode oscillation has its noise properties lowered under the influence of return light from 30 an end portion of the optical fiber. Further, the oscillation of the laser beam is made unstable by the return light. Accordingly, an optical output fetched from

the module and monitor current are rendered unstable.

In order to use the device A as a reliable pumping light source for optical fiber amplifier, therefore, it is necessary to solve the above problem that is attributable
5 to single longitudinal mode oscillation.

The result (2) implies the following situation. In consideration of gain differences caused between the longitudinal modes for single longitudinal mode oscillation for the aforesaid reason, the longitudinal mode hopping
10 occur which causes substantial discontinuous fluctuations of the optical output when the gain band shifts to the longer wavelength side in response to temperature rise. When the injected current almost reaches the level A_1 , therefore, the current-optical output characteristic loses
15 its linearity, so that the first kink (a_1) is generated.

Then, the inventors hereof observed a far field pattern of the device A and obtained the findings shown in FIG. 5.

In FIG. 5, curve C_1 represents a transverse
20 oscillation mode for the case where the injected current is lower than A_2 , and curve C_2 represents a transverse oscillation mode for the case where the injected current is near A_2 (or where the second kink a_2 is generated).

If the injected current increases to A_2 , as seen from
25 FIG. 5, unit-modal transverse oscillation modes shift horizontally from the center position of the device A (or undergo beam steering). Thus, the direction of emission of the laser beam changes.

In the case where the module is constructed by
30 connecting the optical fiber to the device A, therefore, the optical output fetched through the optical fiber fluctuates when the injected current reaches a value

approximate to A_2 . This is supposed to result in the generation of the second kink (a_2) in the current-optical output characteristic curve.

5

OBJECT AND SUMMARY OF THE INVENTION

An object of the present invention is to provide a semiconductor laser device of the gain-waveguide type, capable of oscillating in a longitudinal multi-mode without generating any kinks in a current-optical output
10 characteristic curve even with use of an injected current of 500 mA or more.

Another object of the invention is to provide a novel semiconductor laser device adapted for use as a high-reliability pumping light source for optical fiber
15 amplifier and connected to an optical fiber to form a module, in which a bad influence of return light can be restrained and there is no possibility of beam steering in a far field pattern, so that fluctuations of fetched optical output can be inhibited.

20 The inventors hereof conducted the following examinations in the process of investigation to achieve the above objects. These examinations will be described first.

(1) First, single longitudinal mode oscillation occurs with high probability in the case of a semiconductor
25 laser device that oscillates in a short-wavelength band of about 0.98 μm . If the injected current increases, the longitudinal mode hopping occurs which causes substantial fluctuations of the optical output. This results in the development of a first kink (a_1) in a current-optical
30 output characteristic curve.

It is known that the intervals between the longitudinal modes are proportional to the reciprocal of

the cavity length (L) of the device. Therefore, the intervals between the longitudinal modes can be shortened by increasing the cavity length (L) of the device, so that fluctuations of the optical output caused by the jumping of
5 the longitudinal modes can be reduced, supposedly.

(2) Further, a shift of transverse oscillation modes (beam steering) that causes a second kink (a_2) is a phenomenon that takes place from the following cause. As the injected current increases, rise of the temperature is
10 accelerated by resistance heating. The refractive index of a region near the active layer is increased by the thermal lens effect, so that the distribution width of light in the horizontal direction is reduced. Accordingly, the carrier density of a light distribution area is lowered by spatial
15 hole burning of carriers, so that the refractive index increases further. In the end, the refractive index distribution in the horizontal direction is disturbed, so that the transverse light confinement effect is lowered.

In order to prevent the generation of the second kink,
20 therefore, it may be advisable to design the device (cavity) so that its resistance heat is small even when high current is injected. To attain this, it is necessary only that the cavity length of the device be increased to lower the resistance of the device.

25 (3) If the cavity length (L) of the device is increased, in this case, the quantum efficiency lowers inevitably. However, this can be avoided by using a low-reflection surface as the quantum surface of the device.

In consideration of these circumstances, the
30 inventors hereof varied the cavity length (L) of the device A and examined the current-optical output characteristic of the device. Thereupon, the inventors found that the

linearity of the current-optical output characteristic curve can be secured by adjusting the cavity length (L) to a value not smaller than the value mentioned later, and developed the semiconductor laser device according to the
5 present invention.

Thus, according to the invention, there is provided a semiconductor laser device comprising: a laminated structure of a semiconductor material including an active layer formed of a quantum well structure; a low-reflection film formed on one end face of the structure; and a high-reflection film formed on the other end face of the structure; and the cavity length of the device being 1,200
10 μm or more.
15

Preferably, the device has a transverse light confinement structure with the transverse refractive index difference of about 1×10^{-2} for oscillation modes, the reflectance of the low-reflection film on the one end face is 5% or less, and the active layer is formed of one or two quantum well structures.
20

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a side view of a laser device A of the gain-waveguide type;

FIG. 2 is a sectional view taken along line II-II of
25 FIG. 1;

FIG. 3 shows a current-optical output characteristic curve for the device A of FIG. 1 (for the case of the cavity length of 800 μm);

FIG. 4 shows an oscillation spectrum of the device of
30 FIG. 1;

FIG. 5 is a graph showing transverse modes for a far field pattern of the device of FIG. 1;

FIG. 6 is a graph showing the relation between the cavity length (L) of the device and the current value for the generation of a kink (a_1):

5 FIG. 7 is a graph showing the relation between the cavity length (L) of the device and the current value for the generation of a kink (a_2):

10 FIG. 8 shows an oscillation spectrum of a device according to the invention with the cavity length of 1,500 μm ; and

15 FIG. 9 shows a current-optical output characteristic curve for the device of the invention with the cavity length of 1,500 μm .

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

20 A device according to the present invention will now be described with reference to a device A shown by FIGS. 1 and 2.

25 The device of the invention has a layer structure such that a semiconductor material is put on a semiconductor substrate by, for example, the MOCVD method, and an active layer 3 is formed of a quantum well structure. InP- and GaInNAs-based semiconductor materials may be used in place of the aforesaid materials for the device A.

30 The most distinguishing feature of the device of the invention lies in the cavity length (L) of 1,200 μm or more.

If the cavity length (L) increases, the intervals between the longitudinal modes which oscillate in the gain band of the oscillation spectrum are shortened in proportion to the reciprocal of the cavity length, as mentioned before. If the cavity length (L) is 1,200 μm or more and if the quantum well structure is formed of InGaAs/GaAs, the interval between each two adjacent

longitudinal oscillation modes is about 0.12 nm spacing. This oscillation spectrum shows a longitudinal multi-oscillation mode in which a large number of longitudinal oscillation modes aggregate densely at short intervals in
5 the gain band.

In the case of a module that is formed by connecting an optical fiber to the aforesaid device, therefore, return light from the optical fiber is also based on the longitudinal multi-mode, so that oscillation of a laser
10 beam can be restrained from being made unstable by the return light.

In this longitudinal multi-oscillation mode, moreover, gain differences between the longitudinal modes are so small that fluctuations of the optical output are small
15 even if the longitudinal modes jump. In consequence, the first kink (a_1) ceases to be generated in the current-optical output characteristic.

In order to obtain more stabilized the longitudinal multi-oscillation mode, the volume of the active layer that
20 is formed of the quantum well structure should preferably be reduced. More specifically, it is advisable to use one or two quantum well structures to form the active layer.

If the volume of the active layer is reduced, the value β_{SP} in expression (1) becomes greater, so that single
25 longitudinal mode oscillation is restrained. If the active layer volume is lessened, moreover, the internal loss of the cavity is reduced, so that the optical output can be improved.

If the cavity length (L) is 1,200 μm or more,
30 furthermore, the volume resistance of the cavity is lowered. If the injected current is increased, therefore, the temperature of the active layer is restrained from rising,

so that the laser beam no longer can be moved. In consequence, dislocation of transverse oscillation modes (beam steering), which occurs with conventional devices, never takes place, so that the second kink (a_2) cannot be
5 generated in the current-optical output characteristic.

Thus, in the case of the device according to the present invention, the cavity length (L) is adjusted to 1,200 μm (or more), so that the kinks a_1 and a_2 cannot be generated in the current-optical output characteristic
10 curve, and therefore, the linearity of the curve can be maintained.

Since the increase of the cavity length (L) results in a reduction of the quantum efficiency, however, a low-reflection film should preferably be formed on one end face
15 (front facet) of the cavity in the device of the invention.

More specifically, a low-reflection film with a reflectance of 5% or less is formed on the one end face of the cavity, and a high-reflection film with a reflectance of 80% or more on the other end face.

20 [Example]

1. Manufacture of Device

A lower clad layer 2 of n-AlGaAs with a thickness of 2 μm , an active layer 3 formed of two quantum well structures of InGaAs and GaAs, an upper clad layer 4 of p-AlGaAs with a thickness of 2 μm , and a cap layer 5 of p-GaAs with a thickness of 0.3 μm were successively stacked in layers on the (100) surface of an n-GaAs substrate 1 by the MOCVD method. Thereafter, the upper part of the resulting layer structure was formed into a mesa structure
25 4 μm wide and 2 μm high, and its whole surface was coated with a passivation film 6 of SiN. The back surface of the substrate 1 was polished so that the overall thickness of
30

the substrate was about 100 μm . After that portion of the passivation film 6 which was situated on the upper surface of the cap layer 5 was removed, an upper electrode 7 of Ti/Pt/Au was formed on the surface of the resulting structure, and a lower electrode 8 of AuGe/Ni/Au was formed on the back surface of the substrate 1.

After the substrate was then cleft into a bar with a different cavity length (L), a low-reflection film 9 of SiN was formed on one end face S_1 of the bar, and a high-
10 reflection film 10 of SiO_2/Si was formed on the other end face S_2 . Finally, the bar was worked into chips, whereupon devices, such as the one shown in FIG. 1, were obtained.

2. Characteristics of Device

For the devices obtained in this manner, injected
15 currents (hereinafter referred to as kink currents) with which kinks are generated were measured.

The "kink" is defined herein as a state in which the external differential quantum efficiency of an oscillated laser beam is 15% or more, in consideration of the
20 practicality of the device for use as a pumping light source.

FIG. 6 shows the results of measurement on the kink (a_1) that is attributable to jumping of longitudinal modes.

As seen from FIG. 6, the kink (a_1) current value of a
25 device having the cavity length (L) of 800 μm is 200 mA, and that of a device having the cavity length (L) of 1,200 μm is 350 mA. In the case of a device having the cavity length (L) of 1,500 μm , however, currents not higher than 700 mA do not cause generation of the kink (a_1).

30 FIG. 7 shows the results of measurement on the kink (a_2) that is attributable to beam steering for the time of high current injection.

As seen from FIG. 7, the kink (a_2) current value of the device having the cavity length (L) of 800 μm is 400 mA, that of the device having the cavity length (L) of 1,200 μm is 550 mA, and that of the device having the cavity length 5 (L) of 1,500 μm is 700 mA. Thus, the greater the cavity length (L), the higher the current value that causes beam steering is.

This proves that if the cavity length (L) is longer, resistance heat attributable to the injected current is 10 reduced correspondingly, so that the rise in temperature of the active layer can be restrained to ensure a satisfactory transverse light confinement effect by occurring no displacement of the transverse mode field.

In the case where the injected current is at 400 mA, 15 operating voltages for the devices with the cavity lengths of 800 μm , 1,200 μm , and 1,500 μm are 2.1 V, 1.9 V, and 1.75 V, respectively. Thus, the greater the cavity length (L), the lower the operating voltage is.

FIG. 8 shows an oscillation spectrum of the device 20 with the cavity length (L) of 1,500 μm for the case where the injected current is at 200 mA.

As seen from FIG. 8, this device is based on a longitudinal multi-oscillation mode in which a large number of longitudinal modes exist at short intervals in a gain 25 band g. The interval between each two adjacent longitudinal modes is about 0.1 nm spacing.

FIG. 9 shows a current-optical output characteristic curve for this device.

In the case of this device, as seen from FIG. 9, 30 injected currents not higher than 700 mA cause generation of no kinks, and the linearity of the current-optical output characteristic is maintained.

As is evident from the above description, the semiconductor laser device of the gain-waveguide type according to the present invention undergoes longitudinal multi-mode oscillation. In the module that is formed by connecting the device to the optical fiber, therefore, a bad influence of the return light can be restrained, and there is no possibility of dislocation of transverse modes (beam steering) in a far field pattern, so that fluctuations of the fetched optical output can be inhibited.

In consequence, the linearity of the current-optical output characteristic can be maintained as a whole even if the injected current is increased.

Thus, the device according to the present invention, for use as a pumping light source for optical fiber amplifier, is of great industrial value.

WHAT IS CLAIMED IS:

1. A semiconductor laser device comprising:
a laminated structure of a semiconductor material
including an active layer formed of a quantum well
5 structure;
a low-reflection film formed on one end face of the
structure;
a high-reflection film formed on the other end face
of the structure; and
10 the cavity length of the device being 1,200 μm or
more.
2. The semiconductor laser device according to claim
1, wherein said device has a transverse light confinement
structure with the transverse refractive index difference
15 of about 1×10^{-2} for oscillation modes.
3. The semiconductor laser device according to claim
1, wherein the reflectance of said low-reflection film on
the one end face is 5% or less.
4. The semiconductor laser device according to claim
20 1, wherein said active layer is formed of one or two
quantum well structures.
5. The semiconductor laser device according to any
one of claims 1 to 4, wherein the coefficient of light
confinement to the active layer ranges from 1% to 2%.

ABSTRACT OF THE DISCLOSURE

A semiconductor laser device according to the present invention comprises a laminated structure of a semiconductor material including an active layer formed of 5 a quantum well structure, a low-reflection film formed on one end face of the structure, and a high-reflection film formed on the other end face of the structure. The cavity length (L) of the device is 1,200 μm or more. This laser device, which enjoys high kink currents and a 10 satisfactorily linear current-optical output characteristic, is a useful pumping light source for optical fiber amplifier.

FIG. 1

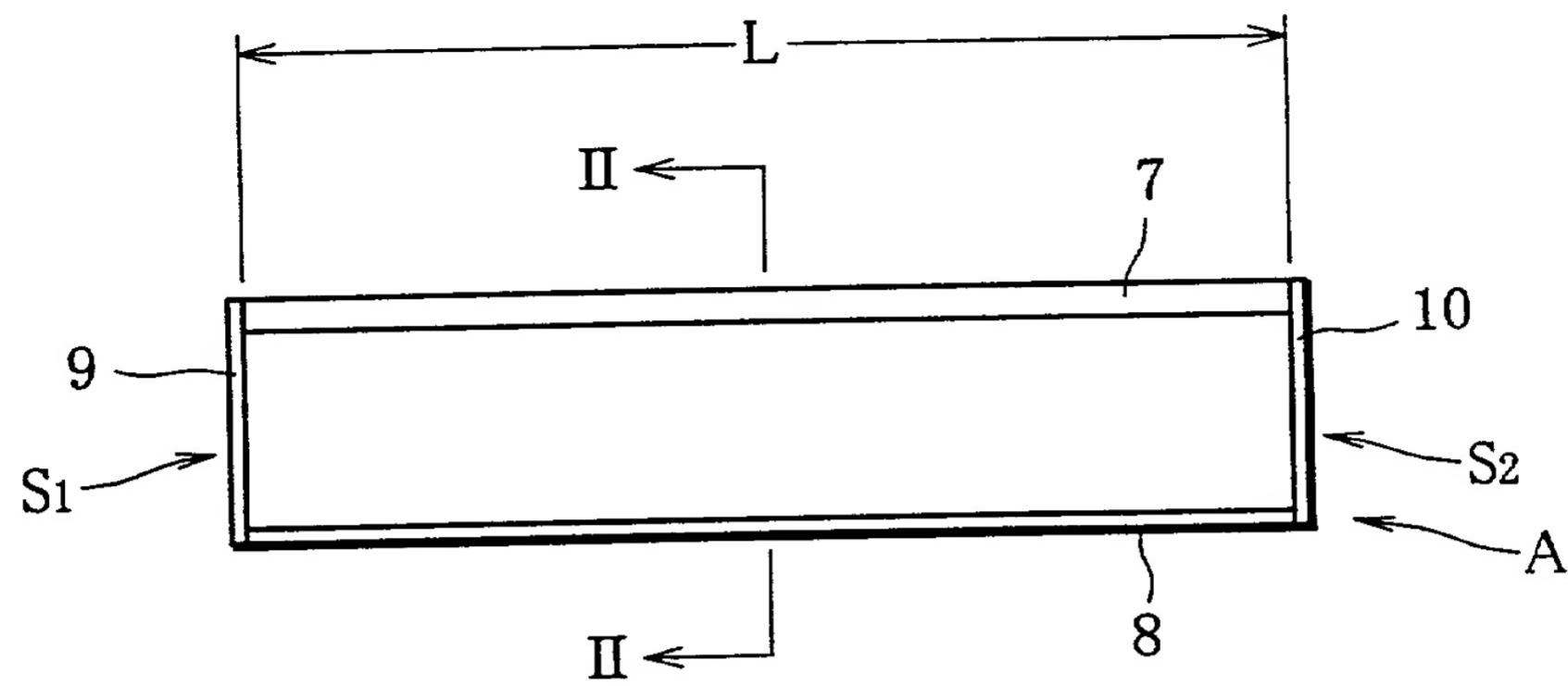


FIG. 2

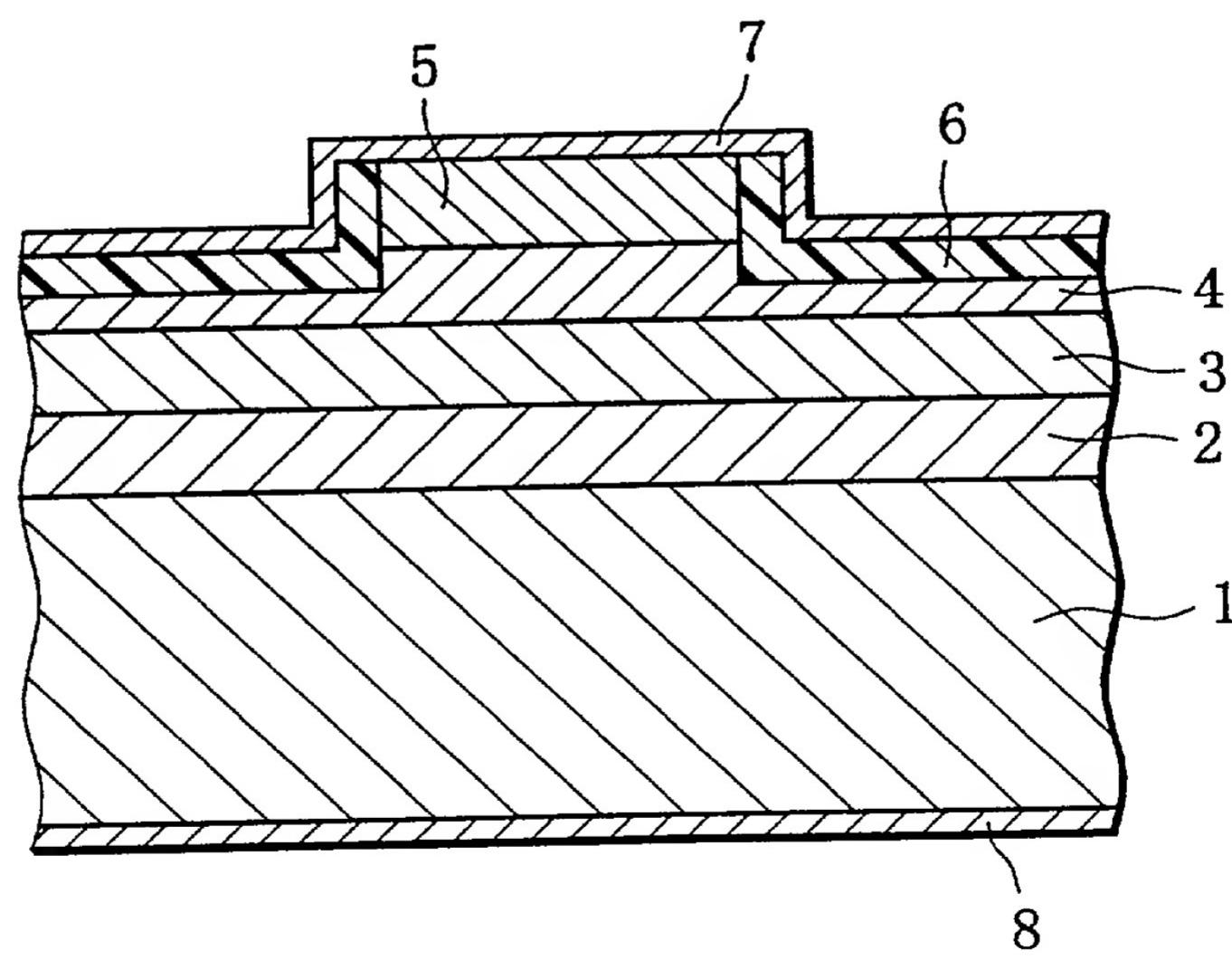


FIG. 3

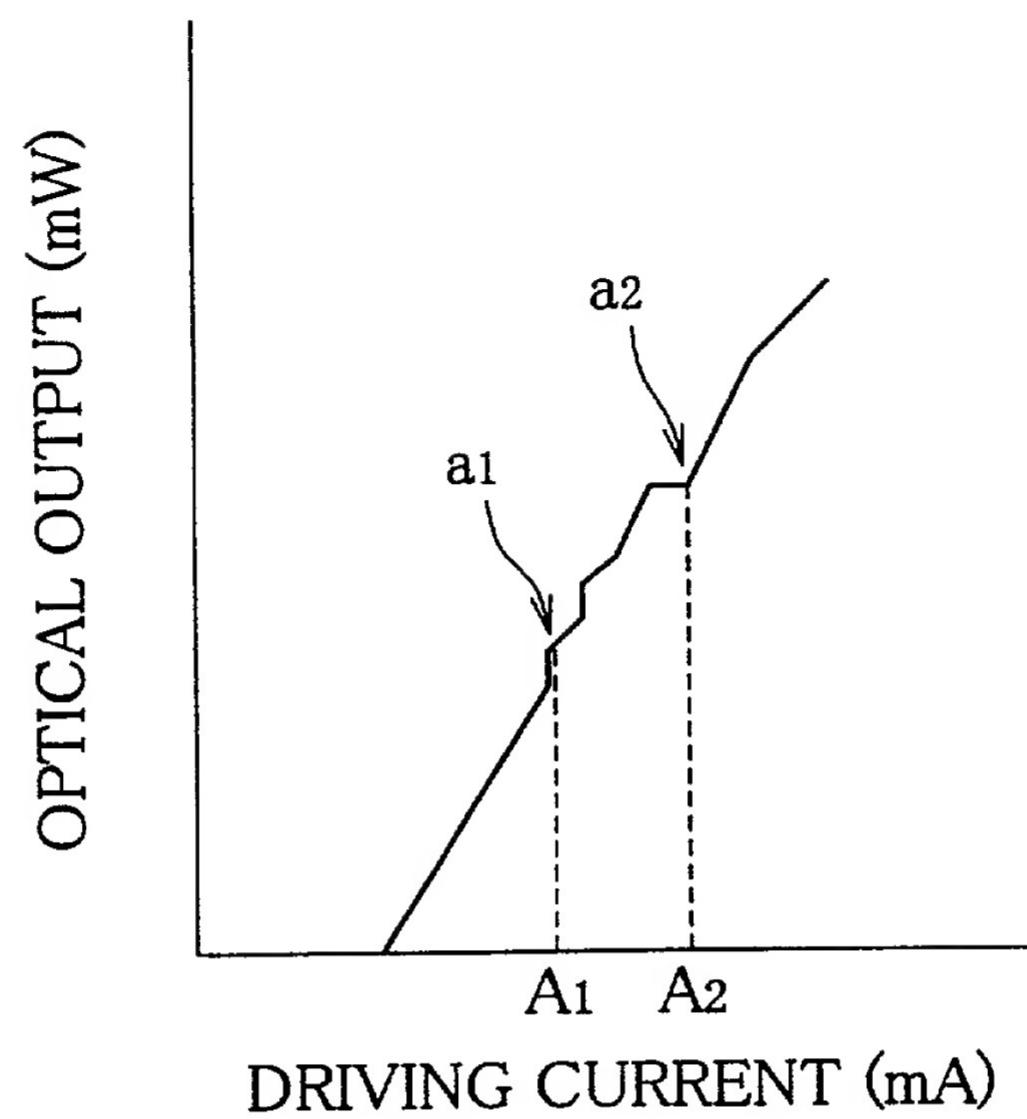


FIG. 4

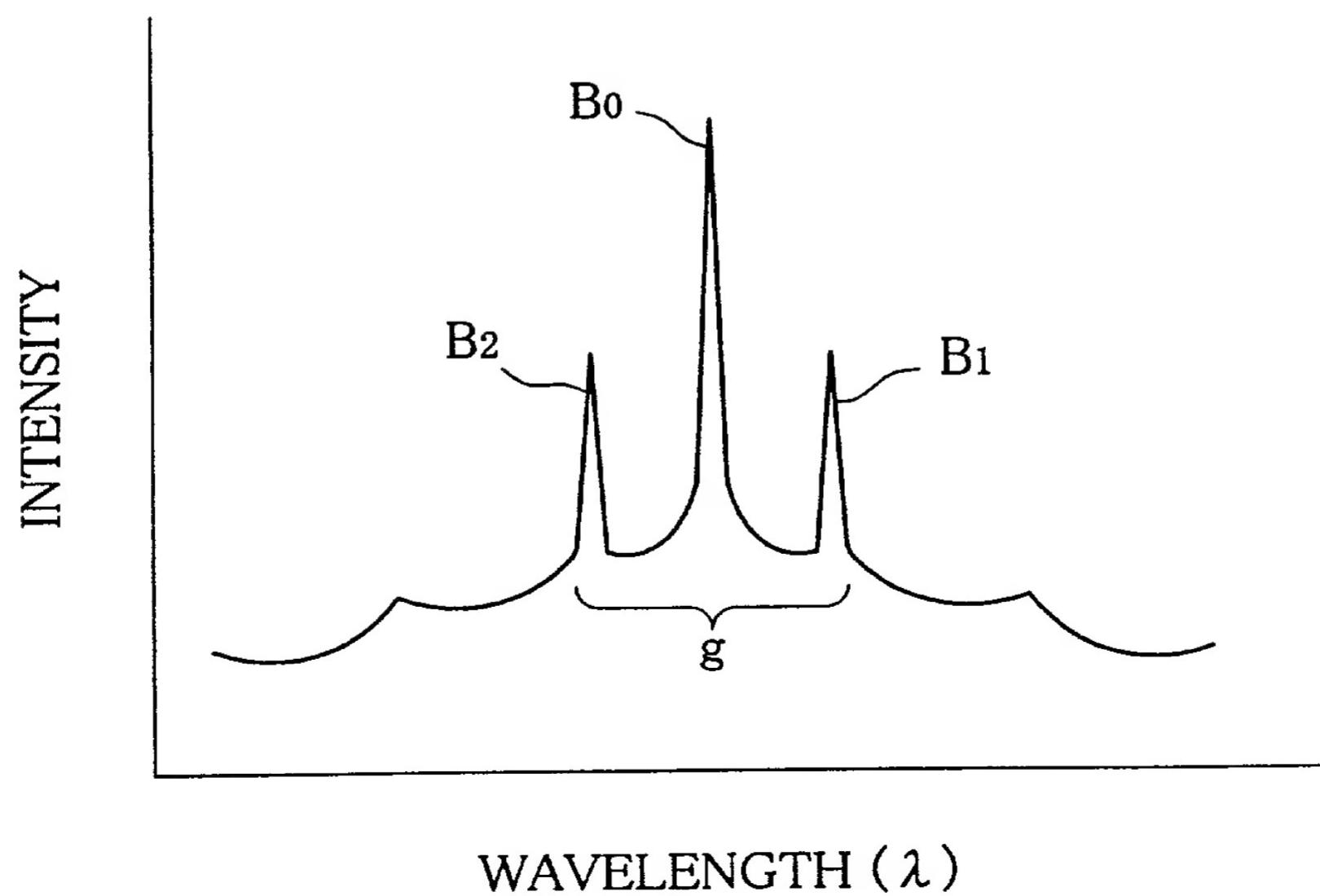


FIG. 5

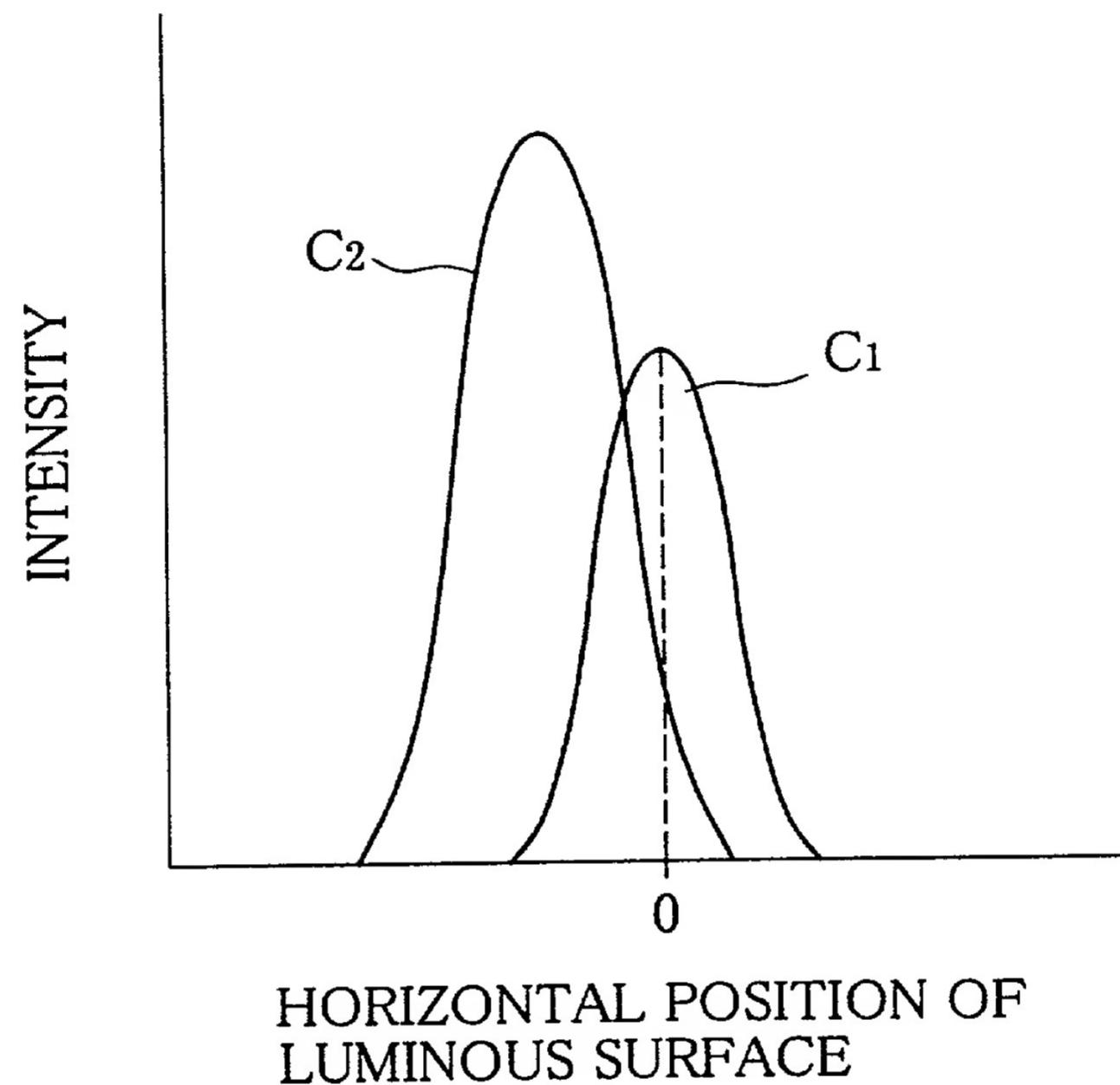


FIG. 6

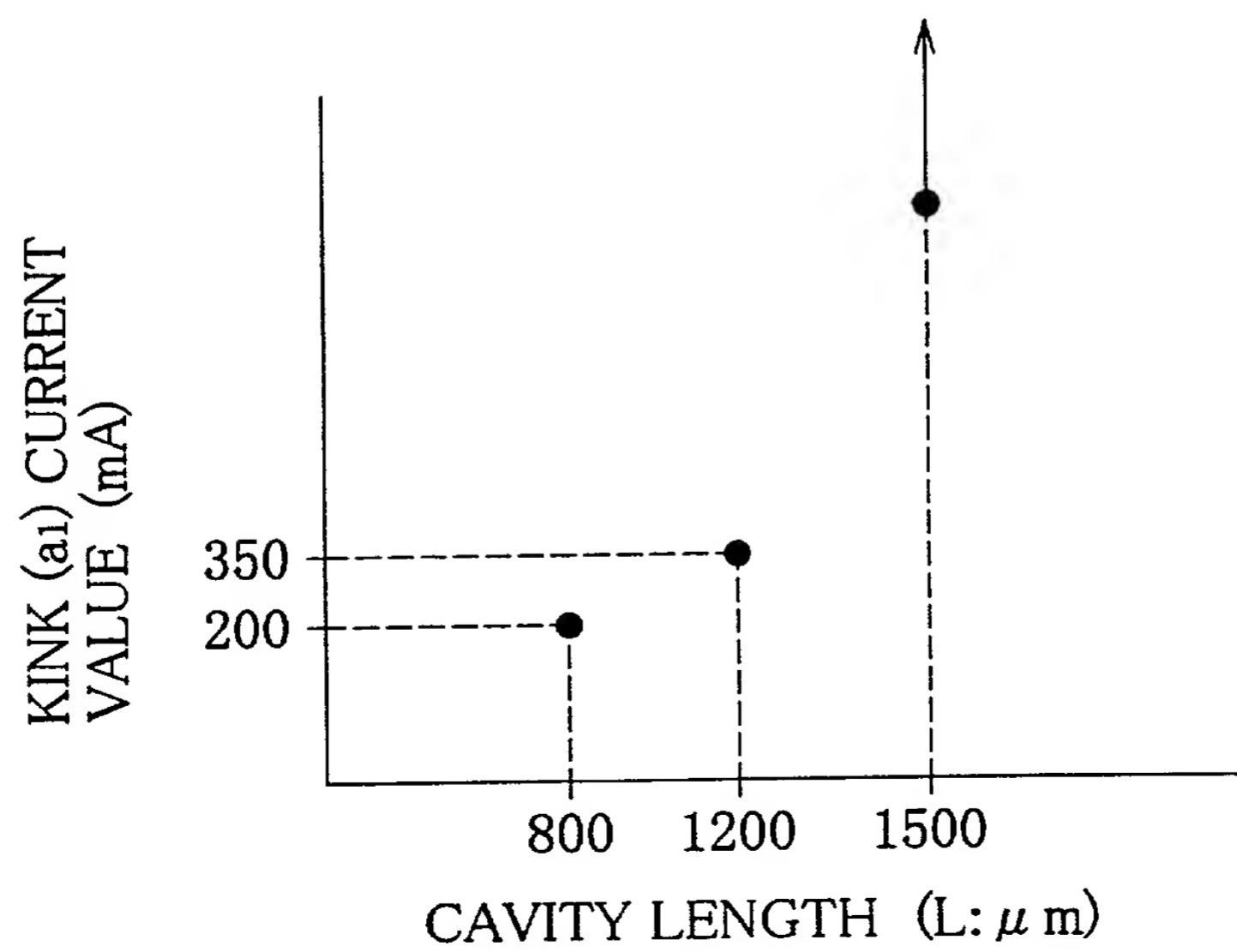


FIG. 7

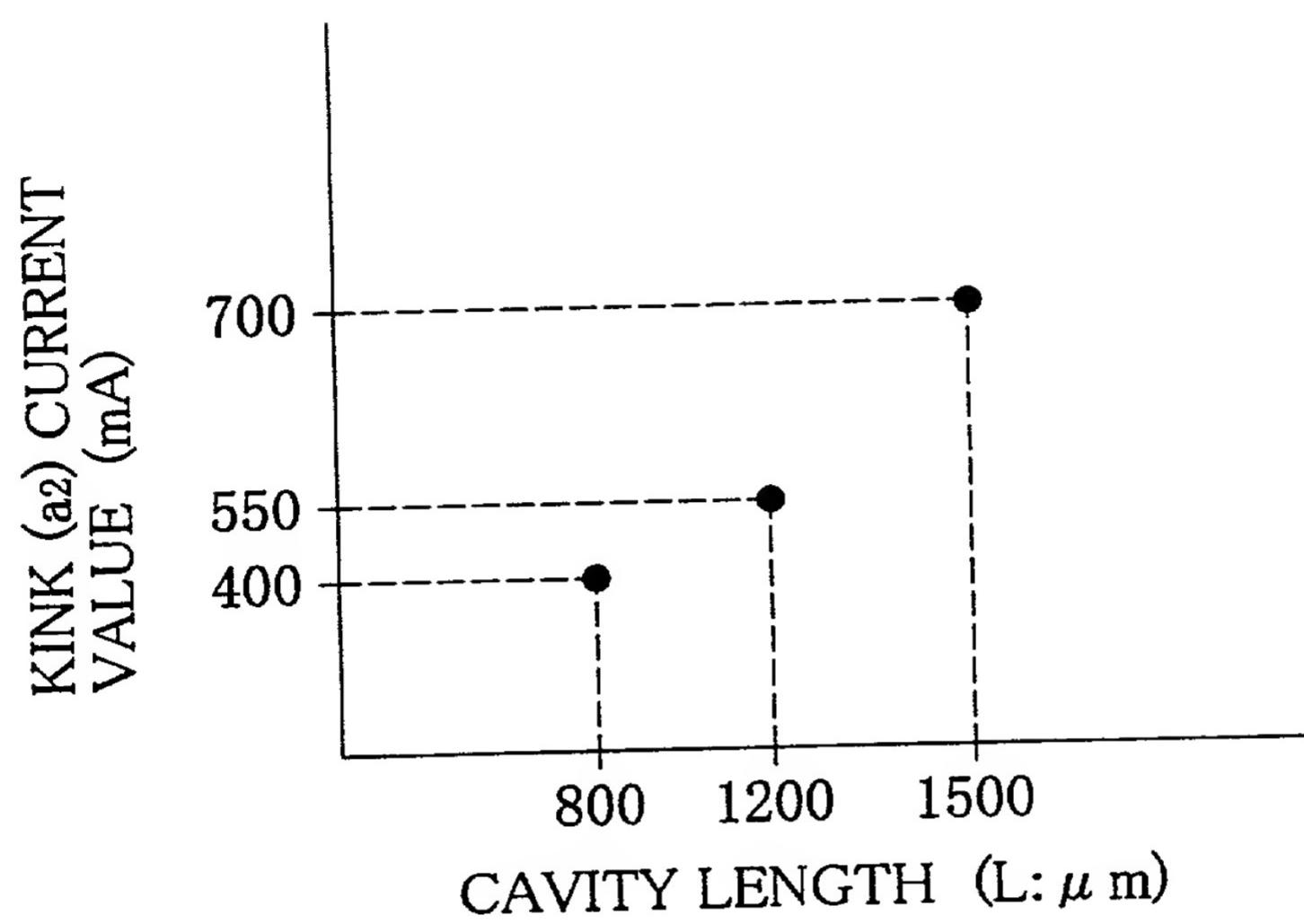


FIG. 8

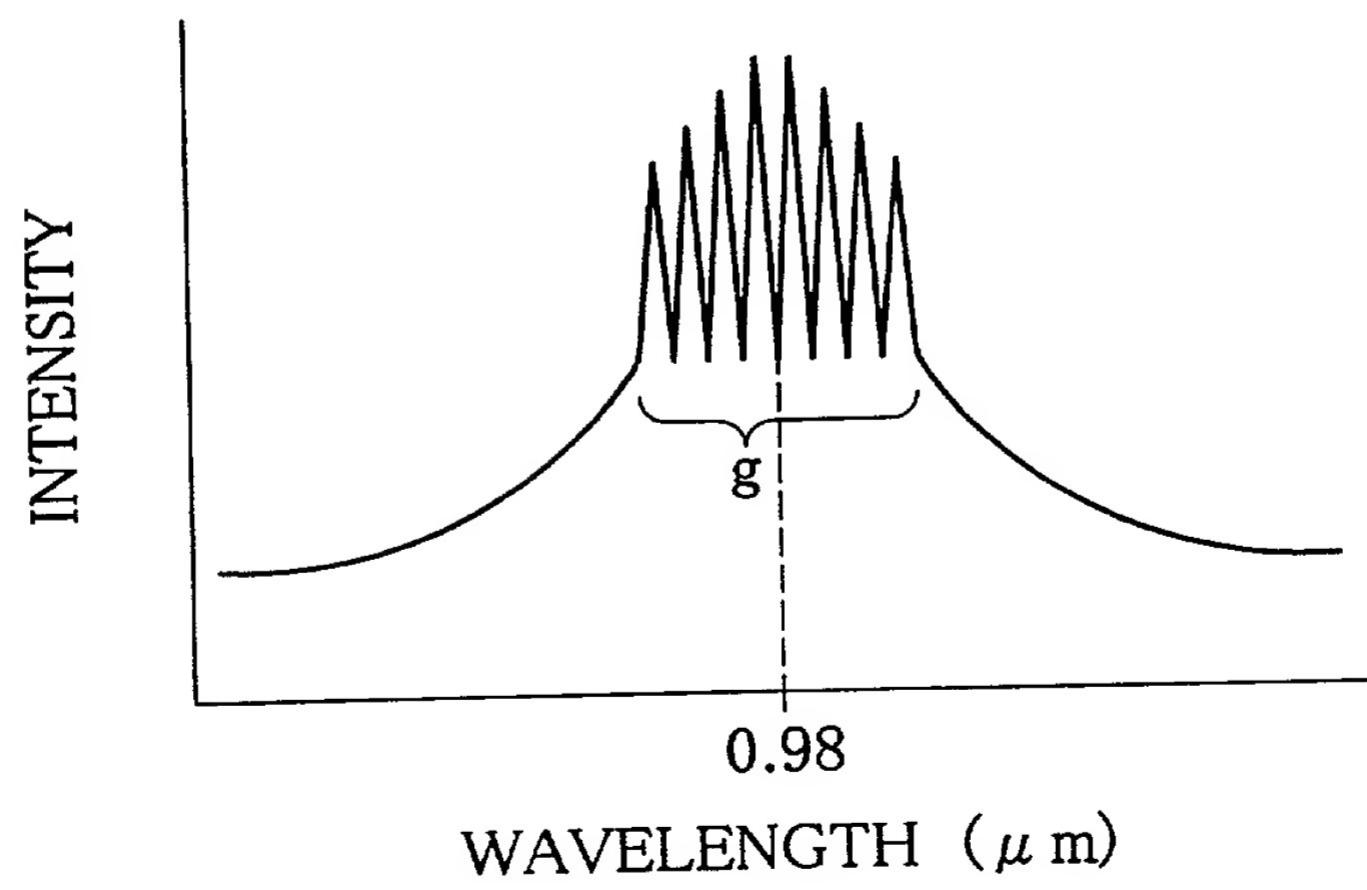
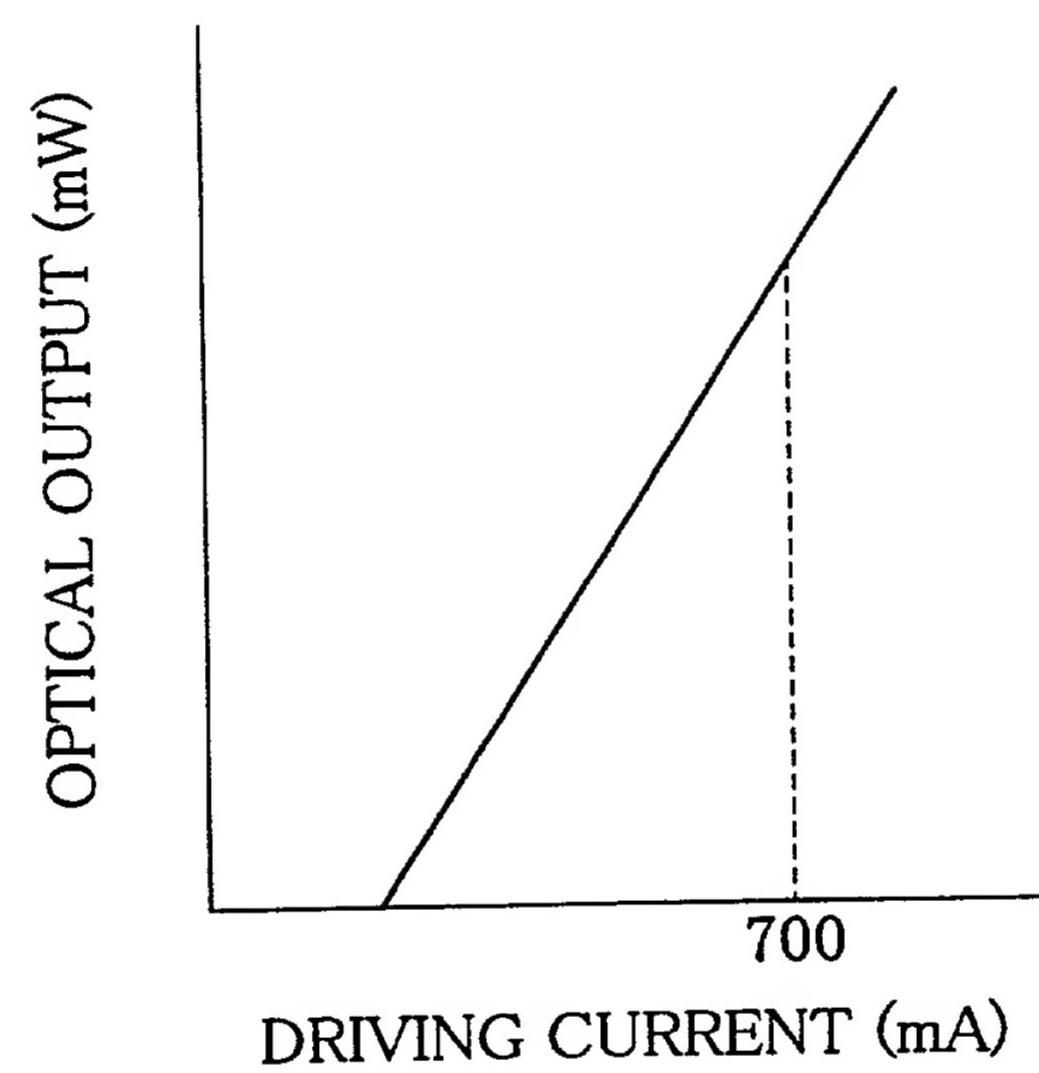


FIG. 9



APPLICATION FOR UNITED STATES LETTERS PATENT**Declaration and Power of Attorney**

As a below named inventor, I declare that:

My residence, post office address and citizenship are as stated below next to my name; I believe that I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled:

SEMICONDUCTOR LASER DEVICE

the specification of which is attached hereto.

I have reviewed and understand the contents of said specification, including the claims.

I acknowledge the duty to disclose information which is material to patentability as defined in 37 CFR §1.56.

I claim priority benefits under 35 USC §119 of: (i) any foreign application(s) for patent or inventor's certificate listed below; or (ii) any United States provisional application(s) listed below; and have also identified below any foreign application(s) for patent or inventor's certificate, or PCT international application having a filing date before that of the application(s) on which priority is claimed.

COUNTRY	APPLICATION NUMBER	DATE (day, month, year)	PRIORITY CLAIMED
Japan	11-162792	09.06.1999	yes <input checked="" type="checkbox"/> no _____
			yes _____ no _____

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

I appoint the following attorneys to prosecute this application and to transact all business in the U.S. Patent & Trademark Office connected therewith: Stephen H. Frishauf, Reg. No. 16,233; Leonard Holtz, Reg. No. 22,974; Herbert Goodman, Reg. No. 17,081; Thomas Langer, Reg. No. 27,264; Marshall J. Chick, Reg. No. 26,853; Walter J. Baum, Reg. No. 20,641; Richard S. Barth, Reg. No. 28,180; Douglas Holtz, Reg. No. 33,902; and Robert P. Michal, Reg. No. 35,614.

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